



National Laboratory in Nanotechnology in Chihuahua and the Nanotechnology Incubator in Monterrey

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Centro de Investigación en Materiales Avanzados, A.C.

3rd TRI-NATIONAL WORKSHOP ON STANDARDS FOR NANOTECHNOLOGIES

*Centro Nacional de Metrología
Querétaro, Qro., Feb., 12, 2009*



www.cimav.edu.mx

Outline

- *General Information about CIMAV (Research Center in Advanced Materials)*
- *Nanotechnology at CIMAV (Chihuahua & Monterrey)*
- *National Laboratory in Nanotechnology at CIMAV (NaNoTeCh)*
- *Diagnostic & Prospective of the Nanotechnology in México*
- *Nanotechnology Incubator at the Research & Innovation Technology Park at Monterrey*





Monterrey



CONACYT Public Research Centers System



CONACYT

Consejo Nacional de Ciencia y Tecnología

- Total
27 CONACYT
Public Research Centers

- Located in
24 States
42 Cities

- 10 Exact & Natural Sciences
- 8 Social & Humanity Sciences
- 9 Engineering & Technology



Main Facilities



Branches

● Ciudades donde se ubican las Sedes

● Presencia adicional con Subsedes



Chihuahua

www.cimav.edu.mx



CIMAV Personnel

179 Employees

135 Scientific & Technological

- ✓ *40 Full Researchers*
- ✓ *4 Associated Researchers*
- ✓ *67 Full Technicians*
- ✓ *10 Associated Technicians*

56 PhD, and 20 M. D.

8 Support to Research Activities

41 Administrative

Academic Structure

Departments:

- ▶ *Physics of Materials*
- ▶ *Chemistry of Materials*
- ▶ *Environment and Energy*

Institutional Programs:

- *Nanotechnology & Nanoscience*
- *Alternative Energies*

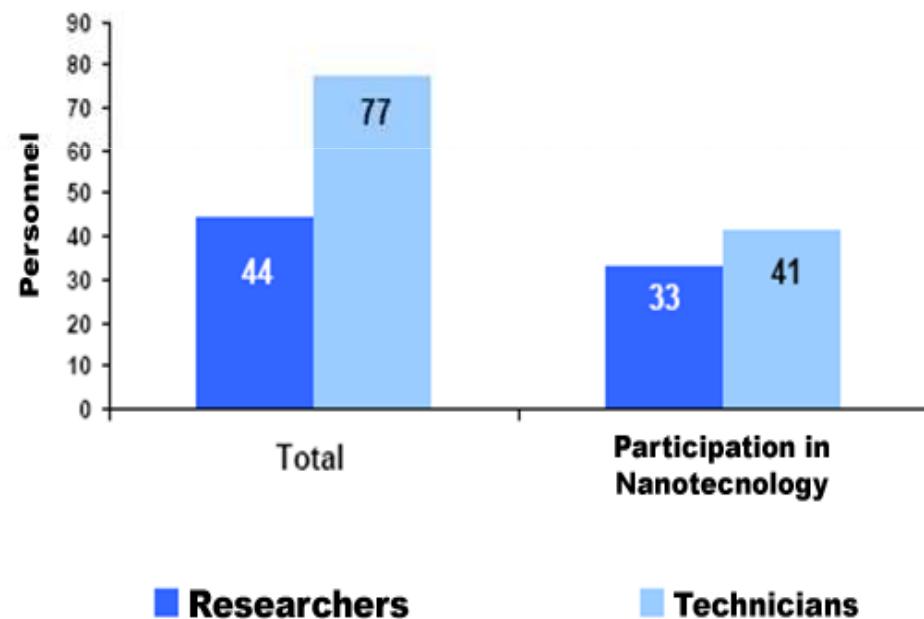


Nanotechnology activities at CIMAV

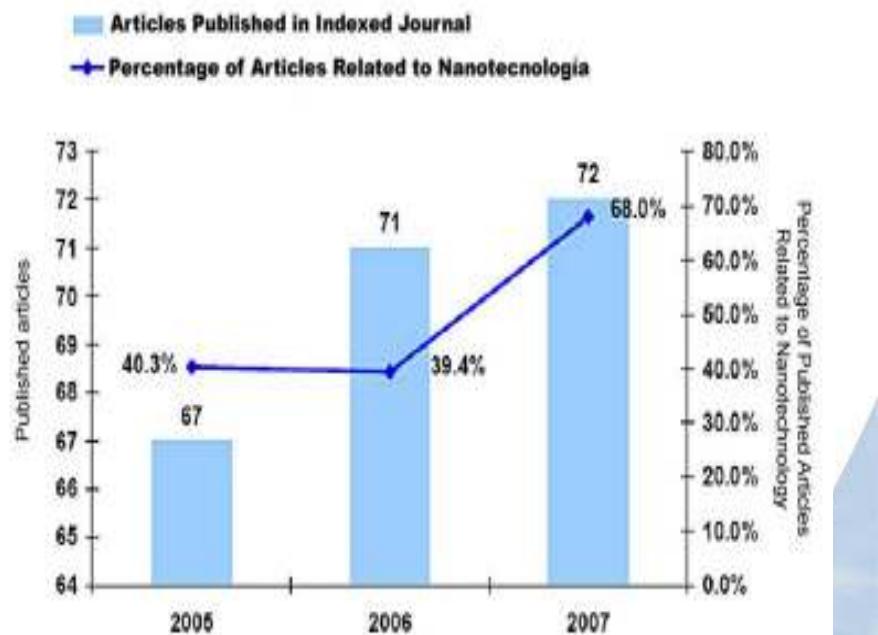
(2007-2008)



*Researchers and
Technicians Working in
Nanotechnology at CIMAV*



*Scientific Articles in
Nanotechnology*



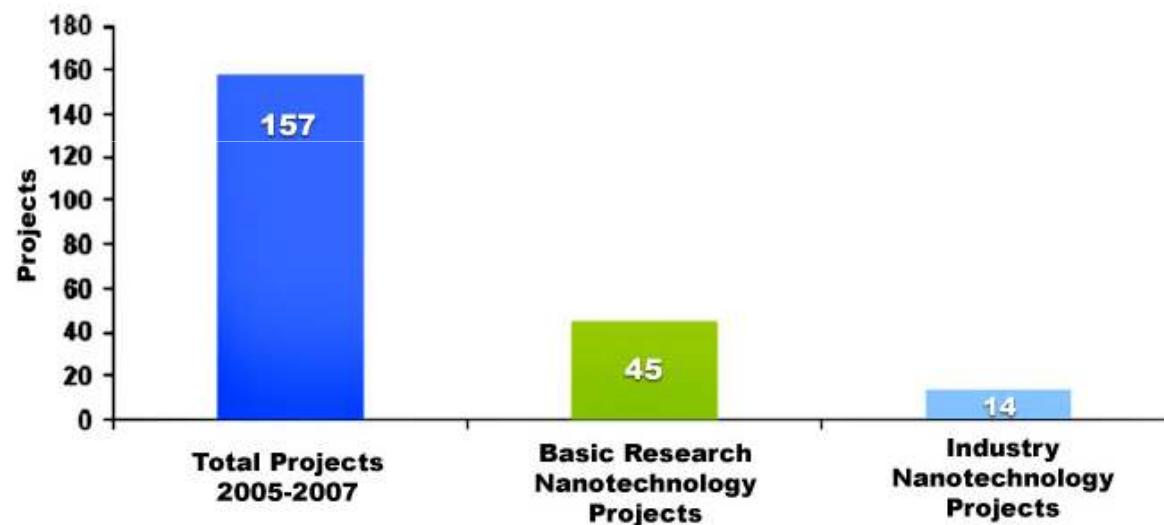
23 Patentes in 2007-2008, 9 in Nanotechnology





Projects and Students in Nanotechnology in CIMAV

Nanotechnology Projects: Basic Research and Industrial



Graduated Students
(Total more than 250)

Graduated with Thesis Oriented to Nanotechnology





National Laboratories

(Federal, Chihuahua State and CIMAV funding)



Results Published by CONACYT, Dec. 2006

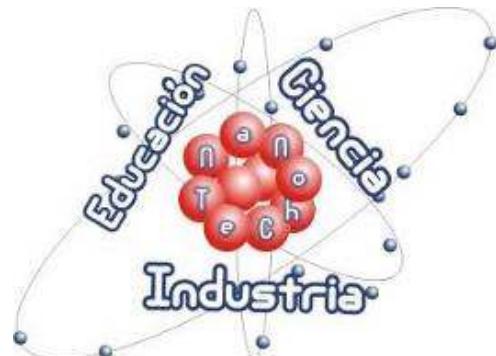
<i>Laboratorio Nacional de Nanotecnología en el CIMAV</i>	CIMAV IPICyT
<i>Centro Nacional de Investigación en Imagenología e Instrumentación Biomédica</i>	UAM
<i>Laboratorio Nacional para la Evaluación de los Recursos Energéticos Renovables en México</i>	IIE
<i>Delta Metropolitana de Cómputo de Alto Rendimiento</i>	UAM
<i>Laboratorio de Microarreglos para Genómica Funcional e Identificación de Organismos</i>	CIAD



Objectives

Support Mexican Organizations to:

- ① Development of human resources
- ② Generate scientific knowledge
- ③ Establishing collaboration mechanisms
- ④ Establishing strategic alliances with high-tech Mexican companies



Experimental Infrastructure

JEOL-2200FS HR-FE-TEM

- *STEM Resolution: 0.07nm*
- *Magnification: up to 1,500,000*
- *STEM Cs corrector*
- *GAT-777 Gatan STEMPACK*

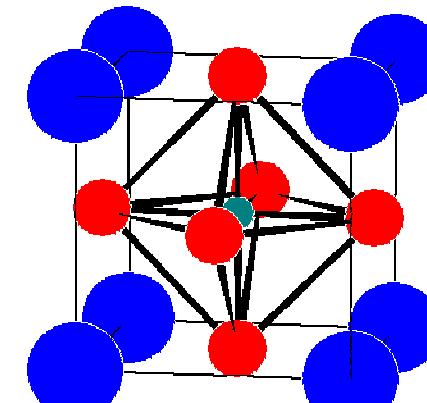
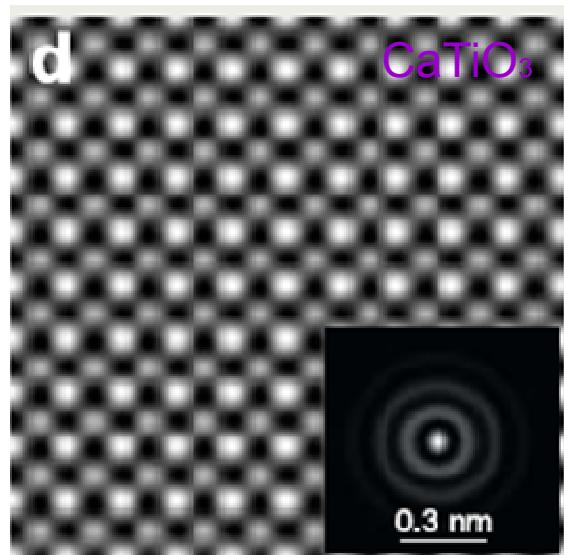
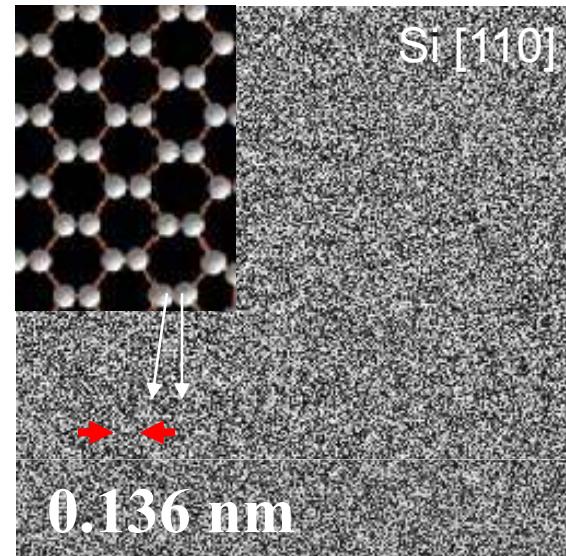
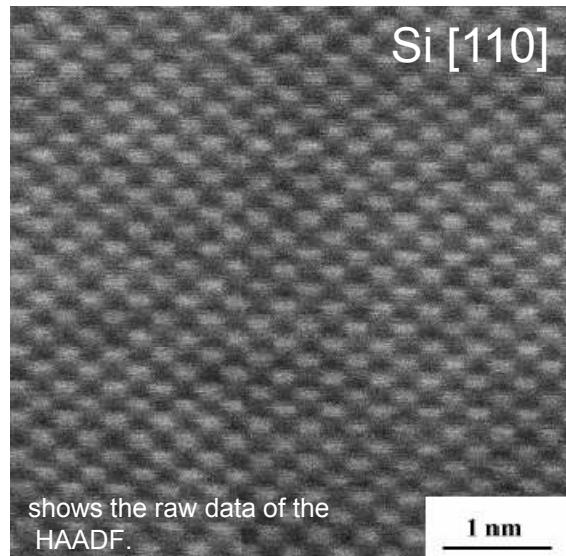


PHILIPS CM-200 TEM

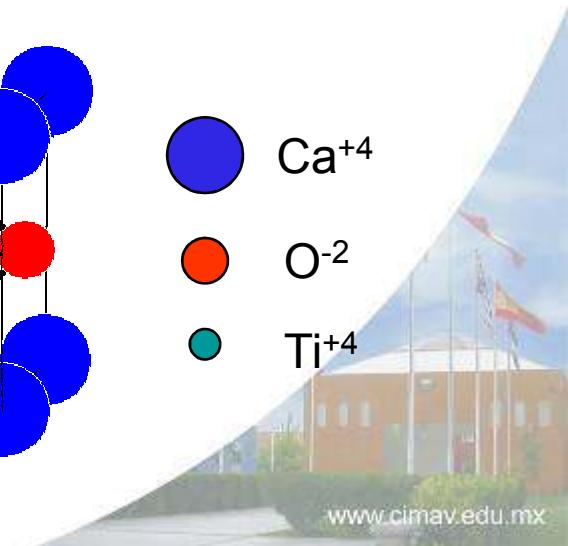
- *Resolution: 0.20 nm*
- *Magnification: 750,000*
- *TEM/STEM modes*



Images obtained with the Jeol 2200 TEM



Ca⁺⁴
O⁻²
Ti⁺⁴





JEOL-7401F FE-SEM

- *Resolution: 1.0nm*
- *Magnification up to 1,000,000X*



Nova 200 NanoSEM HR-FE-SEM

- *Resolution: 0.8 nm, 1,000,000 X*
- *STEM detector*
- *Low-High vacuum*



JSM 5800-LV SEM

- *Tungsten Emission Filament*
- *Maximum Resolution: 3.0 nm*
- *Magnification: 500,000x*



Sample Preparation

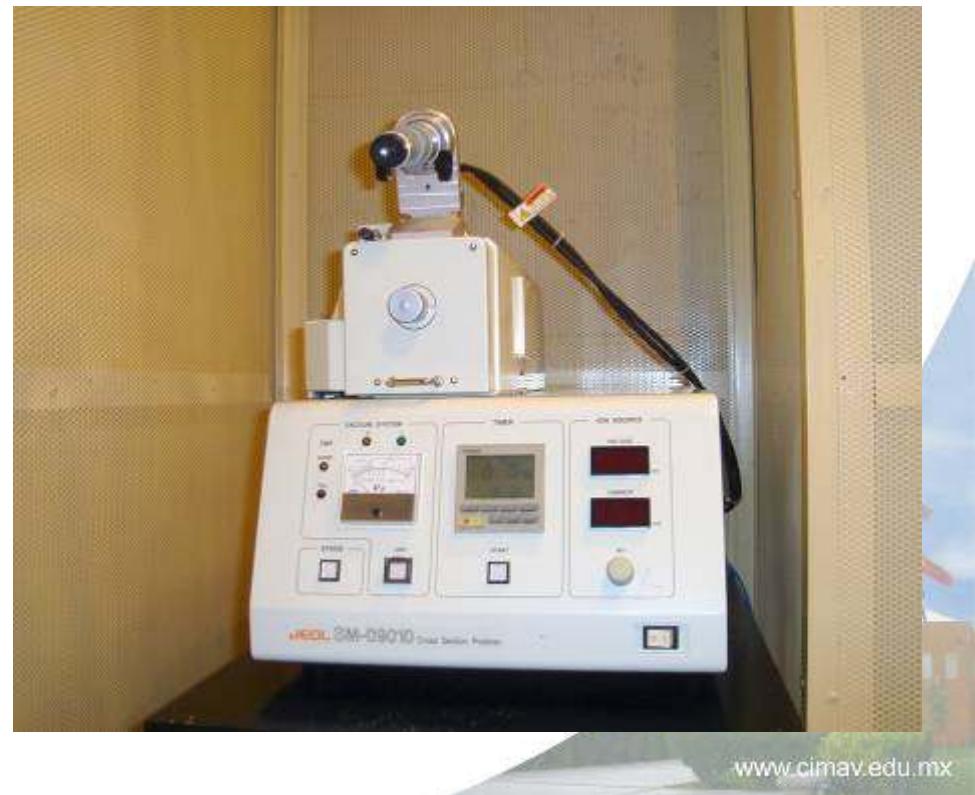
JEOL-9320FIB

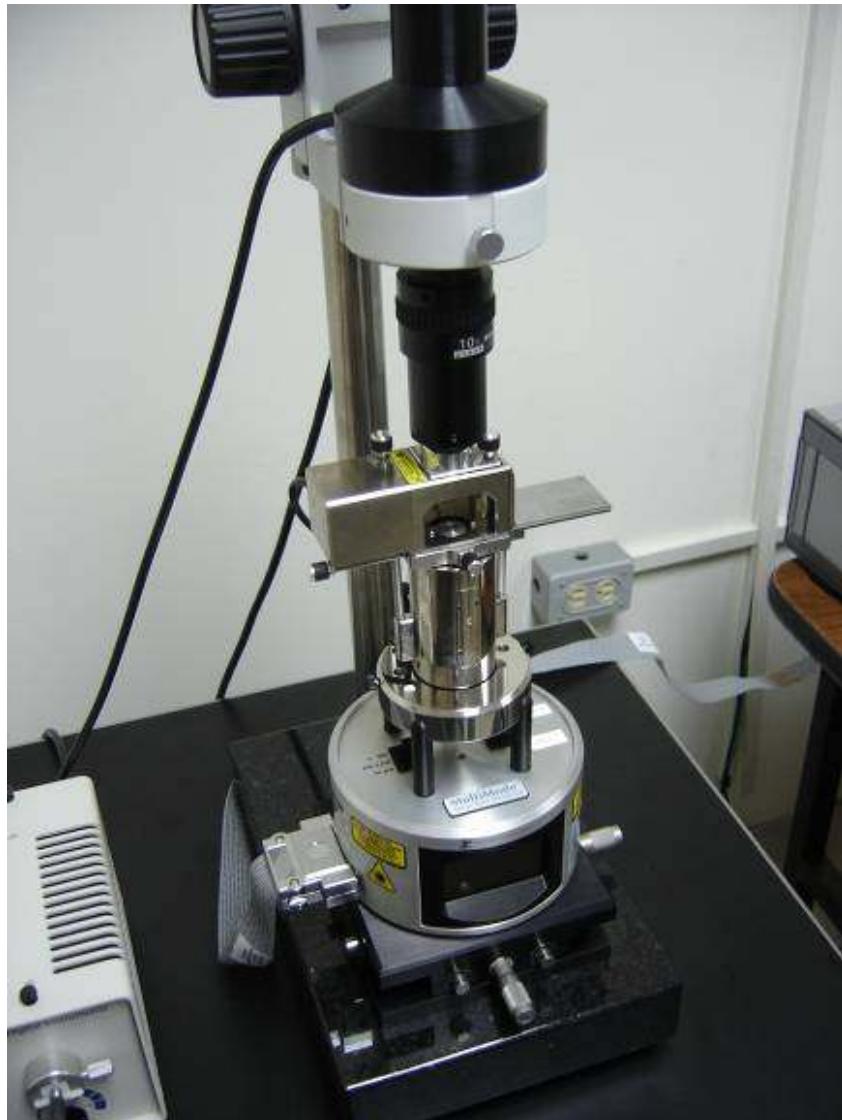
- **Maximum Resolution:** 5.0 nm
- **Magnification:** 400,000x
- **Ion gun:** Ga ion source
- **Metal Deposition Unit**
- **Nanomanipulator**



Plasma Etching

- **Ar plasma etching**
- **Ion Voltage** 2-6 kV
- **Etching speed** 1.3 $\mu\text{m}/\text{min}$ (6kV in Si)





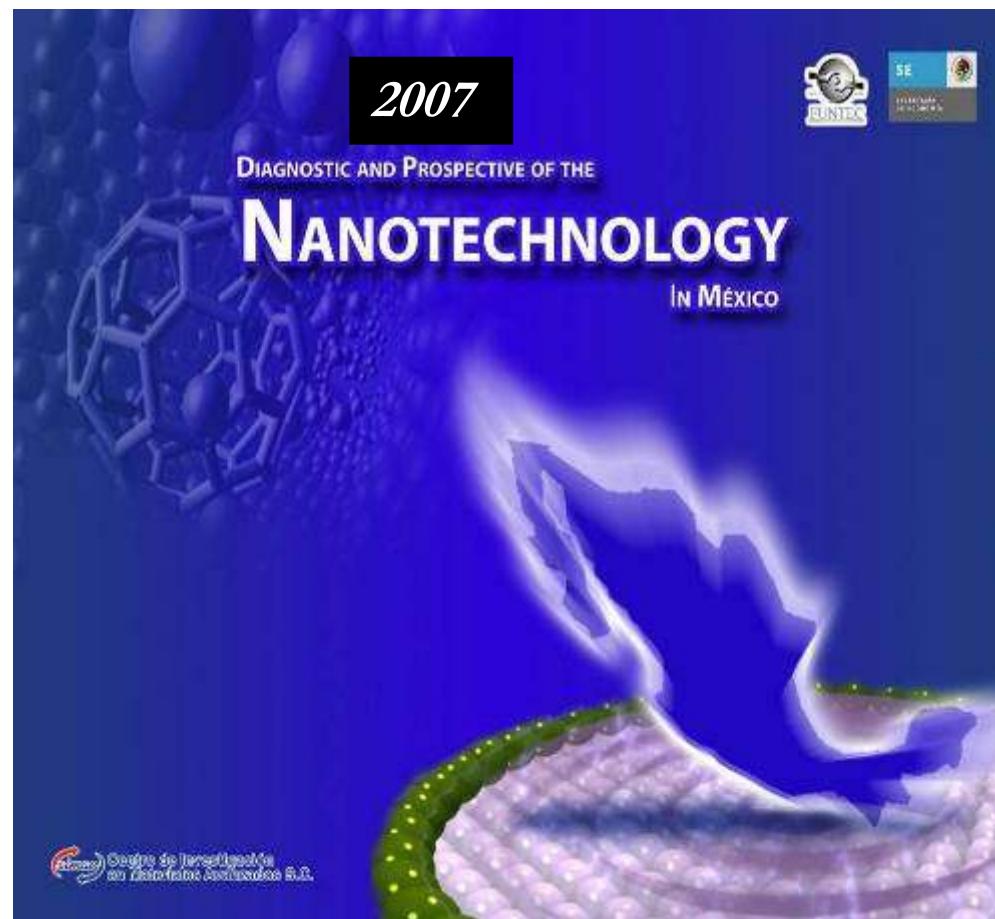
SCANNING PROBE MICROSCOPE

- *AFM Contact Mode*
- *Tapping Mode*
- *Lateral Force Microscopy (LFM)*
- *Magnetic Force Microscopy (MFM)*
- *Scanning Tunneling Microscopy (STM)*
- *Electric Force Microscopy (EFM)*
- *Scanning Capacitance Microscopy (SCM)*
- *Surface Potential Microscopy*
- *Electrochemical Microscopy*
- *Nanoindentation/Scratching*





Nanotechnology in México



Objective:

Identify potential areas of opportunity for Mexico in this megatrend as well as the actions which could be useful in the design and implementation of adequate public policies, for the development of nanotechnology in Mexico

Participants:

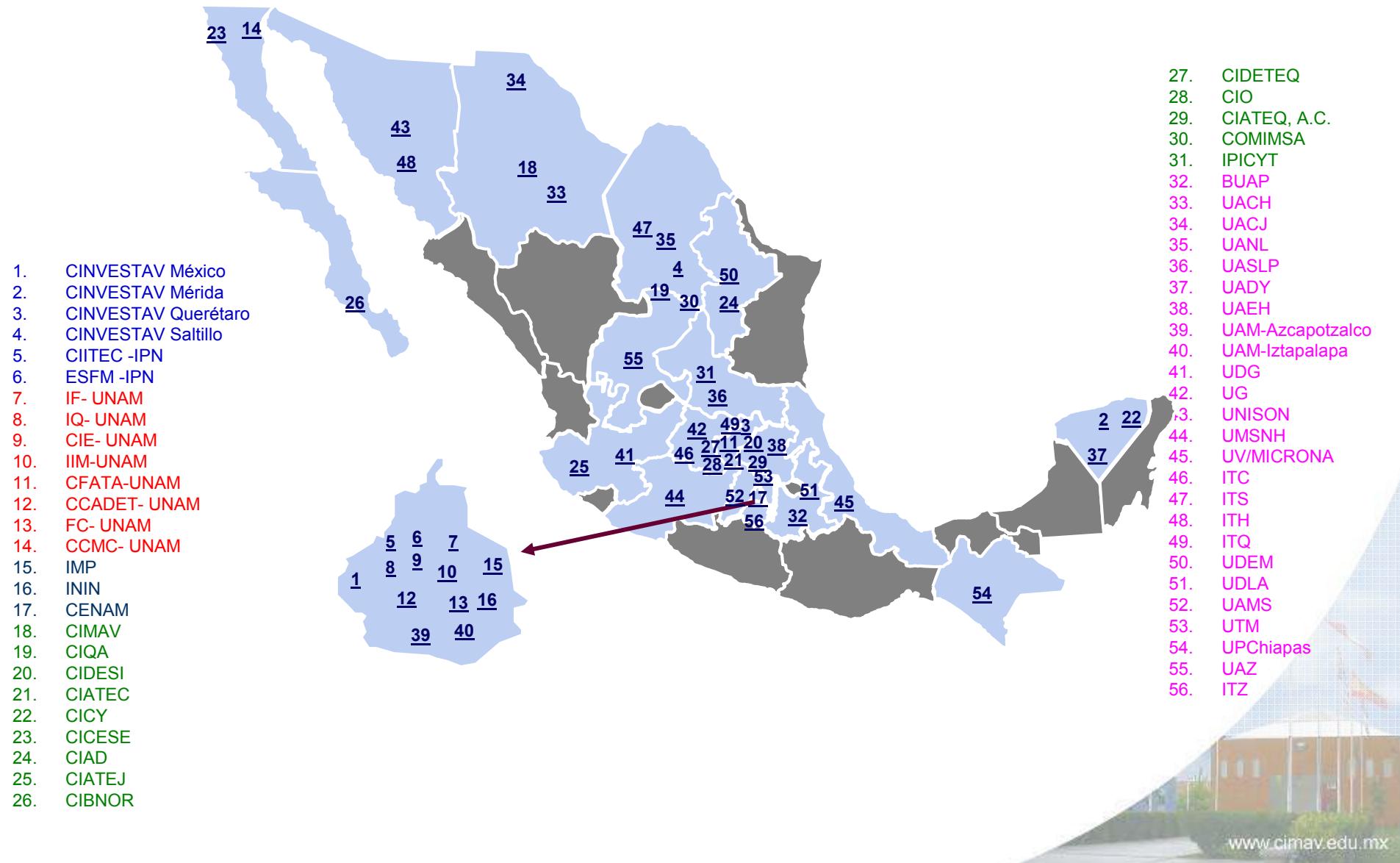
*56 Academic Institutions
101 Companies*

Results:

- Inventory of capacities*
- Key competences*
- Opportunities and niches*
- Public policies*
- Conclusions*



6-IPN	8 - UNAM	3- Research Institutions "Sectorizadas"	14- CPI, CONACYT System	25- IES	56 Institutions
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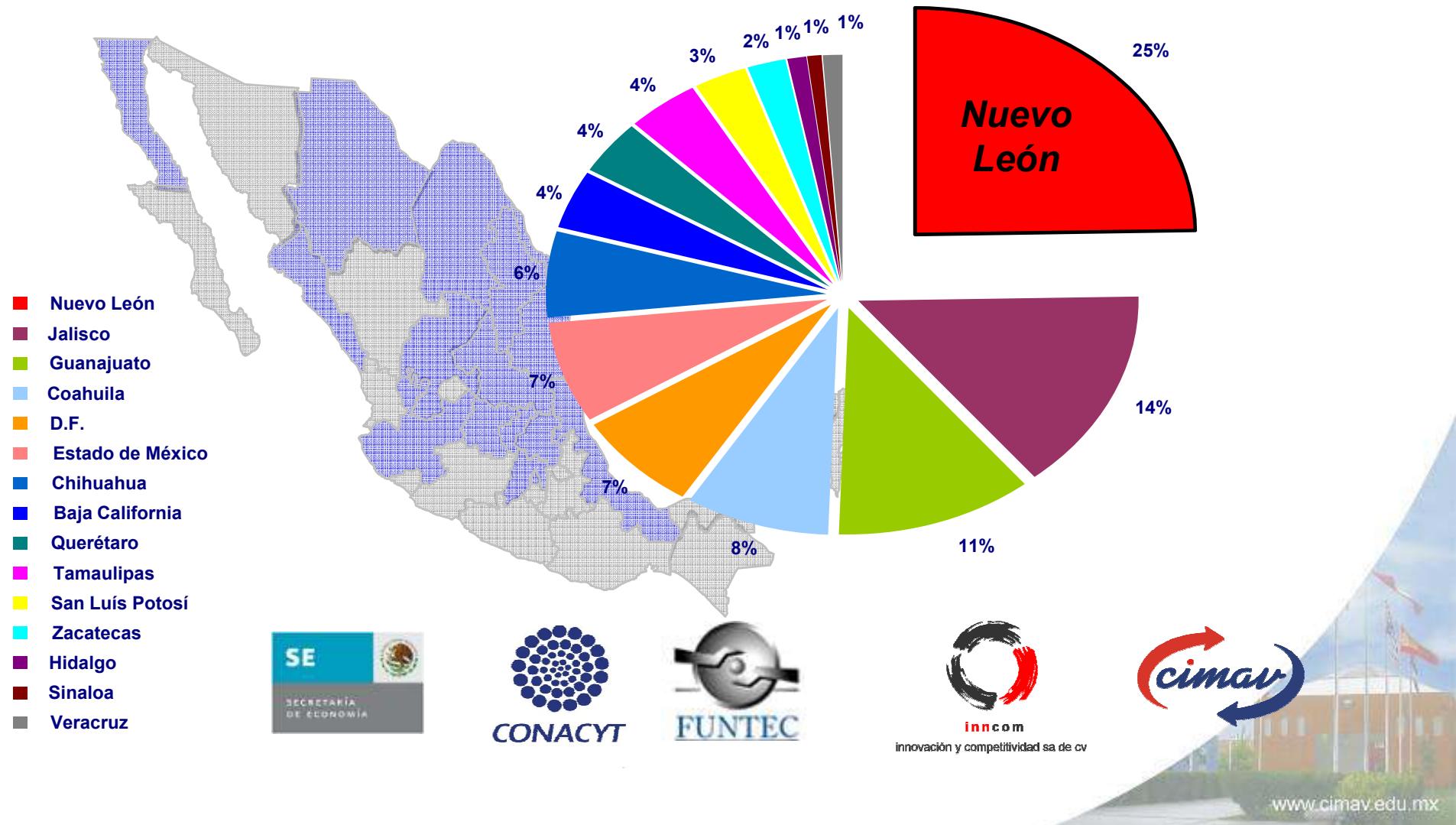




Inventory of Industrial Capabilities



Geographical Location of Surveyed Companies



Opportunities in Nanotechnology in Industry of Nuevo León



Academic & Industrial Capacities

- *8 National Academic Institutions (14%)*
- *3 Foreign Universities*
- *26 Companies (25%)*
- *27 Nanotech industrial projects*

1. The industries with higher interest:

- *Plastics and polymers*
- *Coatings and paints*
- *Glass, Cement, ceramics, textiles*
- *Metal industry (wire, cables and alloys, Cu and Al)*
- *Chemical industry (catalyst, organic synthesis, oil industry)*
- *Electronic industry*

2. What they need, what kind of prime materials?

- *Nanoparticles, {metal oxides, metal chlorides, metal hydroxides, metals (Ag, Au, Pt, Pd, Al, Cu) and nanoclays}*
- *Inorganic nanostructured materials (metal oxides, ceramic compounds)*
- *Polymer composites (nanoclays, nanoparticles specially in PP, PE, Nylon)*
- *Carbon nanotubes*



Strategy for the Development of Nanotechnology in the State of Nuevo Leon



PIIT- Research and Innovation Technology Park

Cluster of Nanotechnology

Instalación del Cluster de Nanotecnología de Nuevo León

Junio de [redacted]

32 | negocios | Junio de 2008 | MILENIO

Integrar cluster de nanotecnología

● Creación de estos materiales beneficiará a empresas como Cemex, Cydsa y otras.

Montejo • Voz calida: Sustancial

N [redacted] que se instaló un nuevo clúster de nanotecnología, que en principio arrancó con un 25 por ciento de las empresas de todo el país, visto el desarrollo tecnológico que ha tenido Nuevo León, éste quedó en el segundo lugar al agrupar al 50 por ciento de las empresas del país ligadas a esta

maquinaria y equipamiento para la fabricación de los materiales como la cerámica, vidrio, cerámica, yeso, entre otros. Al año Nuevo León reportaría una producción superior a las 10 mil toneladas anuales de nano-materiales.

El gobernador del estado, Raúl González Flores, informó que el clúster se establecerá en Monterrey, oficialmente a Jesús González Hermández, como responsable de la reciente agrupación.

Al respecto, el secretario de Desarrollo Económico, José Luis Gómez, detalló que el 15 de junio se instalará formalmente el Clúster de Nanotecnología.

Al respecto, ante Patricia Avila, directora del programa Monterrey Ciudad International del Consejo de Ciencia y Tecnología, detalló que el clúster permitirá la integración de Cemex, Cydsa Lázaro, Ferromex, Villaseca, DeAcero, Vitreox y Xigros.

También están involucradas

organizaciones e instituciones locales, la Universidad de Arizona, tres centros de investigación, con el fin de cooperar, desarrollar capital humano y establecer acuerdos y negocios a través de ese clúster.

A continuación se menciona el establecimiento de este clúster:

En 2010 la entidad pondrá en marcha el Clúster de Nanotecnología, que permitirá la creación de 10 mil empleos y la generación de 10 mil millones de pesos al año.

Incubator for Nanotechnology

**6 Technological Platforms
(Pilot Plants)**

2 Nanoparticles

1 Carbon Nanotubes

1 AACVD Thin Films

1 Application to Final Product



Companies Integrating the Cluster of Nanotechnology of Nuevo León

Cluster of Nanotecnología

16 empresas



viakable



Empresas que integran el Cluster

Cemex Central, S.A. DE C.V.
Cydsa, Corporativo
Lamosa, S.A. de C.V.
MABE, S.A. DE C.V.
METALSA, S. de R.L.
Owens Corning, S de R.L. de C.V.
Palmex Alimentos S.A. de C.V.
Prolec G.E.
SEDEC
Sigma Alimentos
Simplex, S.A. de C.V.
Ternium
Univex, S.A.
Viakable
Vitro Corporativo, S.A. de C.V.
Whirlpool



Academic Institutions Integrating the Cluster of Nanotechnology of Nuevo León

Nationals

- **CIDESI:** Centro de Ingeniería y Desarrollo Industrial (*Design and fabrication of equipment, PP*)
- **UANL:** Universidad Autónoma de Nuevo León (*Nanoparticles and nanomaterials*)
- **CIMAV:** Centro de Investigación en Materiales Avanzados (*Nanoparticles and nanomaterials*)
- **ITESM:** Instituto Tecnológico y de Estudios Superiores de Monterrey (*Nanomaterials*)
- **IIE:** Instituto de Investigaciones Eléctricas (*Nanomaterials and energy applications*)
- **CIQA:** Centro de Investigación en Química Aplicada (*Nanocomposites with polymeric matrix*)
- **CIAD:** Centro de Investigación en Alimentos y Desarrollo (*Nanobiotechnology*)
- **CINVESTAV:** Centro de Investigación y de Estudios Avanzados del IPN (*Nanobiotechnology*)



Foreign

- **Arizona State University :** *Nanotechnology Cluster of North America*
- **University of Texas:** *IC²: Business plans and Tech Transfer, MCS&T*
- **Texas A&M:** *Manufacturing*



Incubator for Nanotechnology

Platforms

Incubator will install equipment with the follow technological platforms

1. *Nanoparticles (top-down, bottom-up)*
 1. *Wet Chemistry*
 2. *Physical-Chemical Methods**
2. *Nanofilms*
 1. *Aerosol Assisted Chemical Vapor Deposition*
3. *Nanocomposites with Polymeric Matrix (PP, PE, Nylon, PVC.)**
4. *Carbon Nanotubes*
5. *Nanobiotechnology (Supercritic Fluids)*

** Foreign Technologies*



Incubator for Nanotechnology

Pilot Plants

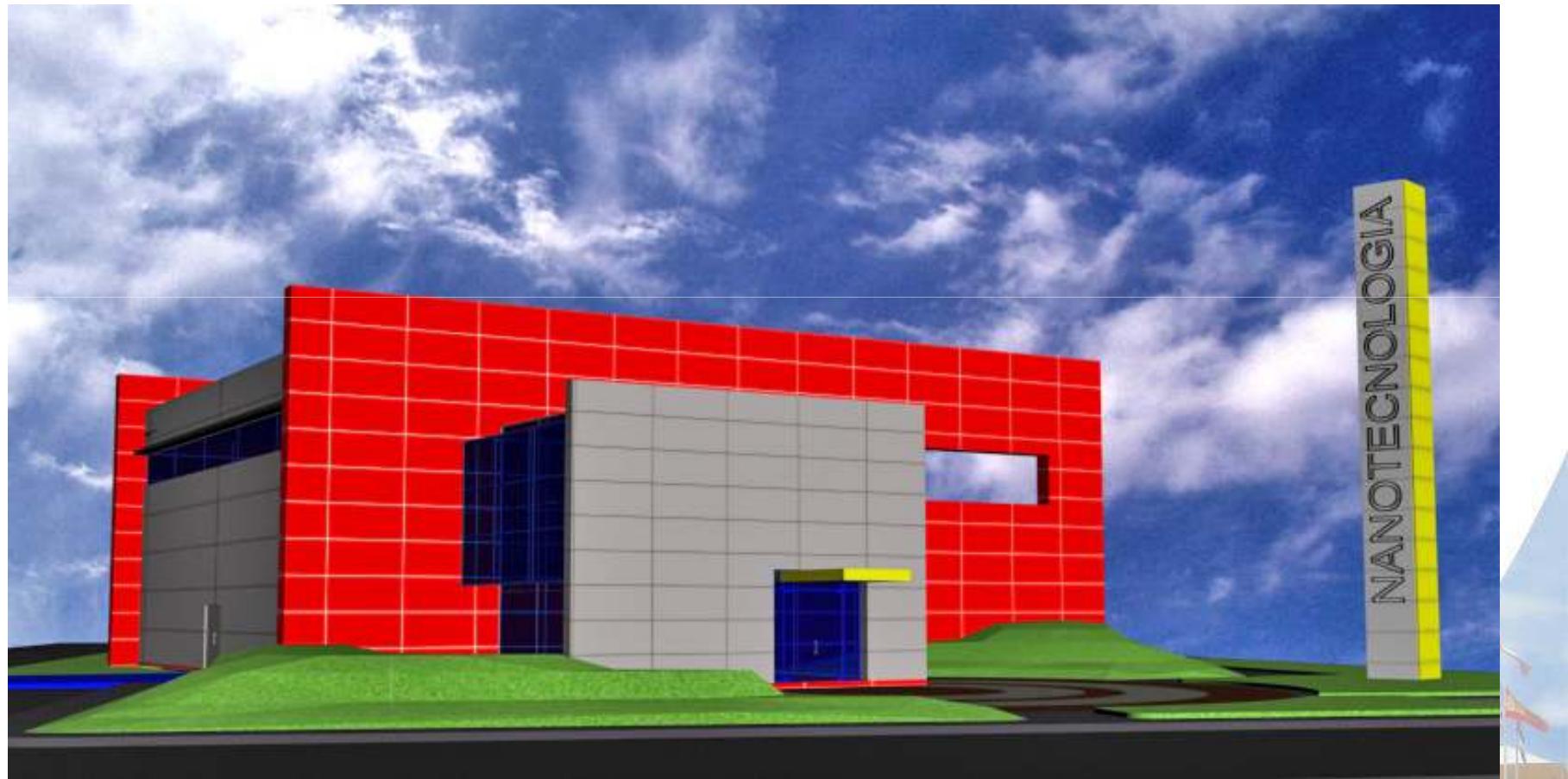
The pilot plants were selected according to the follow considerations:

1. *Patented, patent filed or in process.*
2. *Minimum production capacity kg/h*
3. *Pilot plants must produced a wide range of products and be flexible for experimentation.*
4. *The institution or company must accept one initial payment for the use of the technology, and when some company develop a new product or process with their technology will pay a licensee fee to the technology owner.*





Incubator for Nanotechnology





Incubator for Nanotechnology Location Research and Innovation Technology Park Monterrey, N.L.



N



XETACOMP Physical-Chemical Method

Company Profile

Xetacomp is located at Oklahoma City

The company provides nanomaterials of extremely high surface-area at low cost.

The process can produce a variety of nanoparticles like Titanium Dioxide, Coated Titanium Dioxide, Zinc Oxide, Silicon Dioxide, Nanoclays, Metals and others.

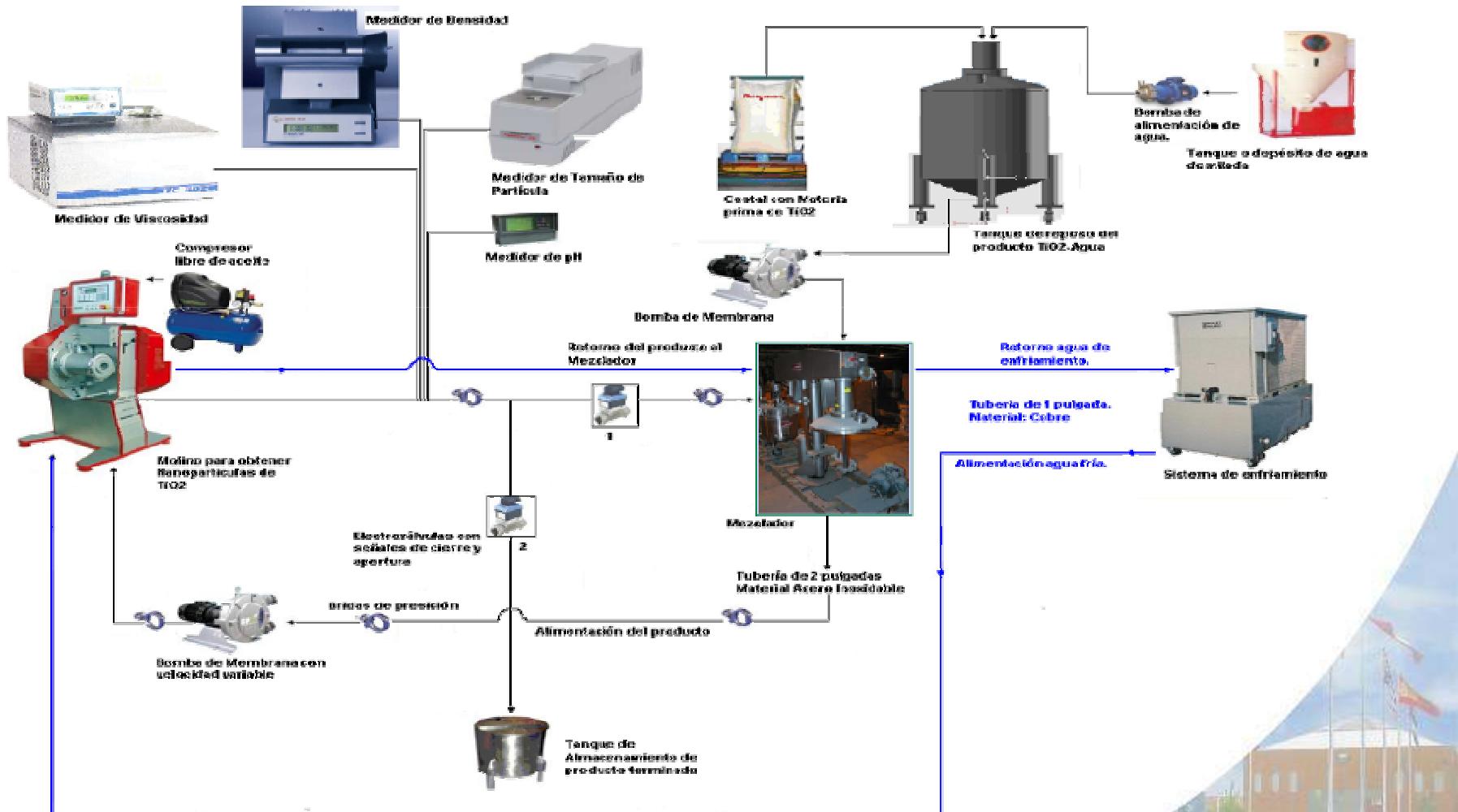
The particle size ranges from 10 to 80 nm in suspension and functionalized for applications in coating, paints, plastics, cosmetics, sunscreens.



Xetacomp developed and sales sunscreens, lotions and creams with the tradename Sunvex based on TiO₂ and ZnO



Technology platform: Physical-Chemical Method XETACOMP





Nanocomposites with Polymeric Matrix

Center for Applied of Nanotechnology (CAN) Hamburg, Germany

Company Profile

CAN is located at Hamburg Germany and offers companies and research institutions **contract research and development services** in the area of nanotechnology

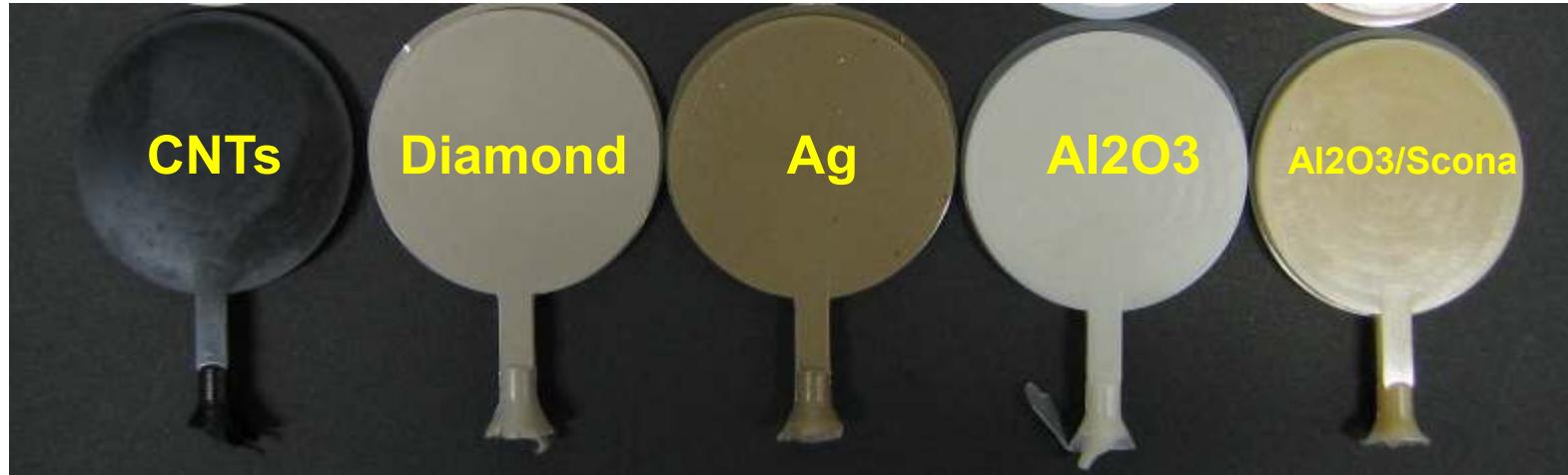
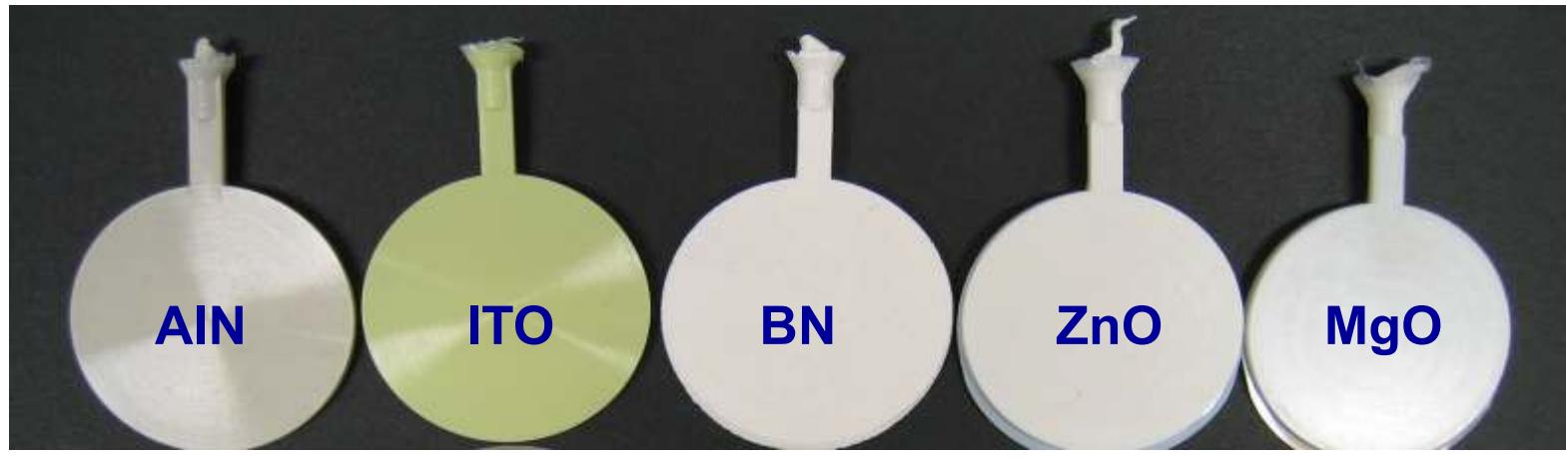
The main **areas of expertise** are the production of:

- nanoparticles and **nanocomposite** materials,
- encapsulation of biological active ingredients
- development of nanoparticle for biological and medical markers

CAN works in association with the **Technical University of Hamburg**.



Polymers with Nanoparticles CAN



Example: PP based nanocomposites (different nanoparticles)
Sample diameter 35 mm, sample thickness 0,5 mm





Modified Sol-Gel Method

Patent filed by the Autonomous University of San Luis Potosí

About the Method and Product

- Modified Sol-Gel Method

Bottom-up: nucleation and growth of particles in wet environments

- Method features

Simple

Friendly with the environment

Scalable

Low cost

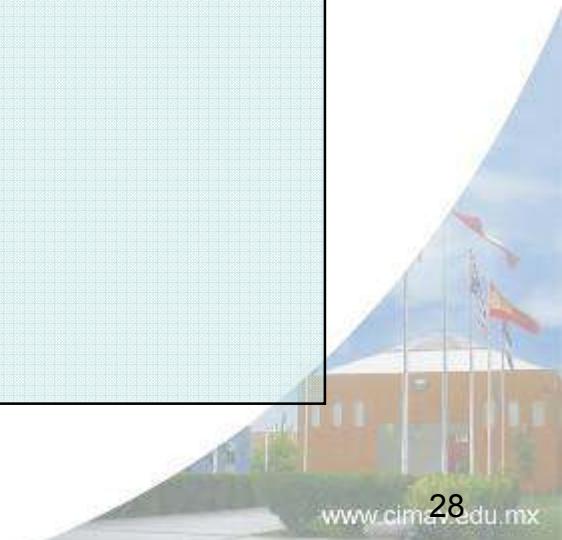
- Nanoparticle features

Sizes < 100 nm (size and shape tunable)

Narrow size distribution

Good dispersion

1 Kg/hr of nAg or 10 Kg/hr of nMg(OH)₂



Modified Sol-Gel Method lay out scheme

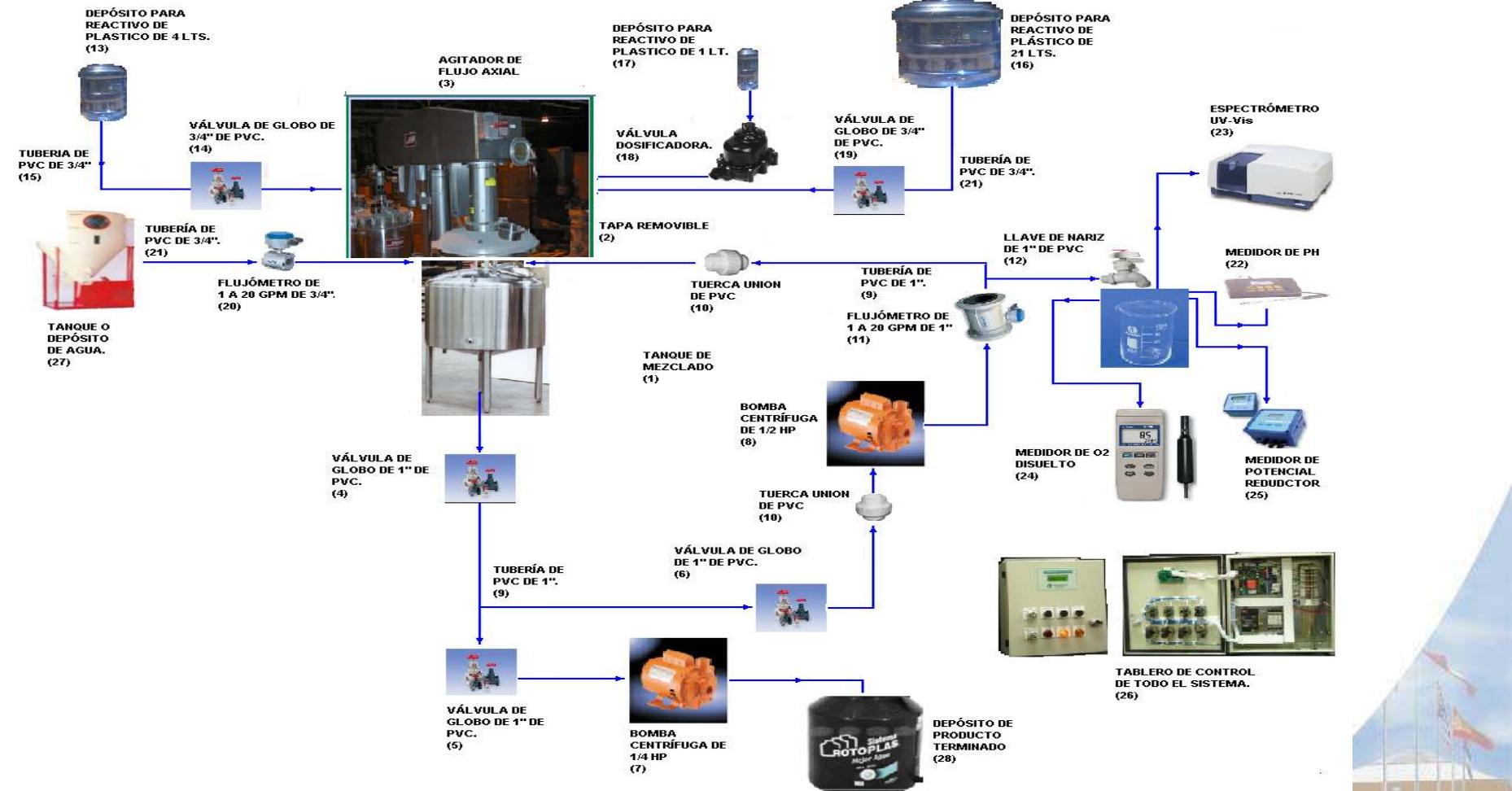


Figura 1. Esquema del Sistema de Producción de Nano-partículas de Materiales Compuestos.



MWCNT Pilot Plant: First prototype (CIMAV)

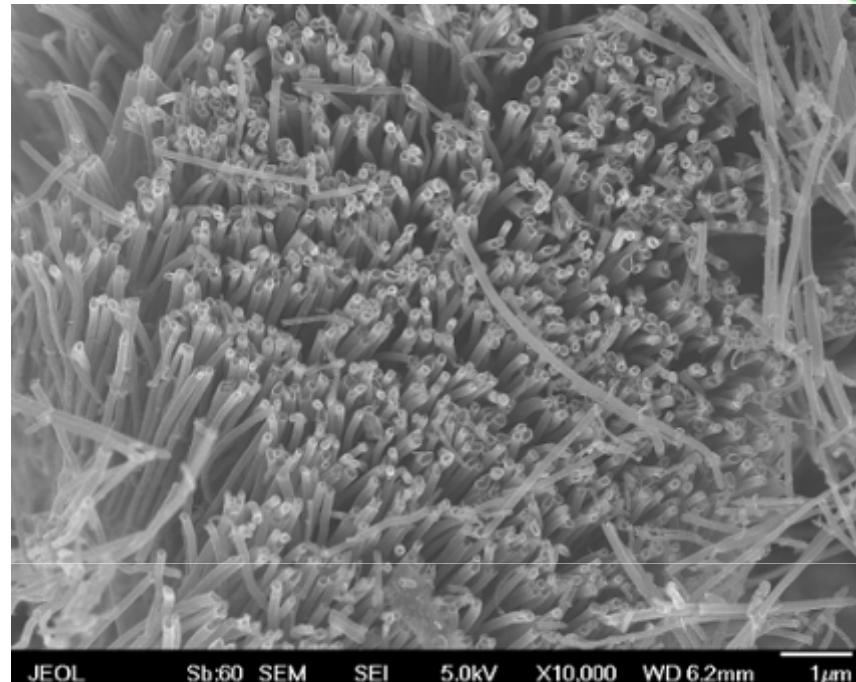
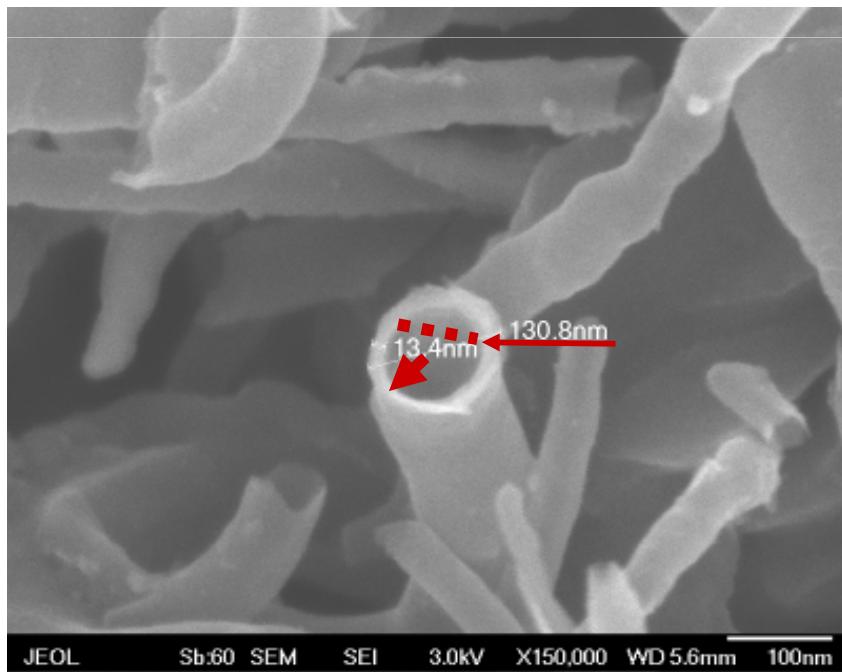


Production capacity: 25 gr/hr

Patent filed by CIMAV

Síntesis of wide CNT with a thin wall

Patent pending



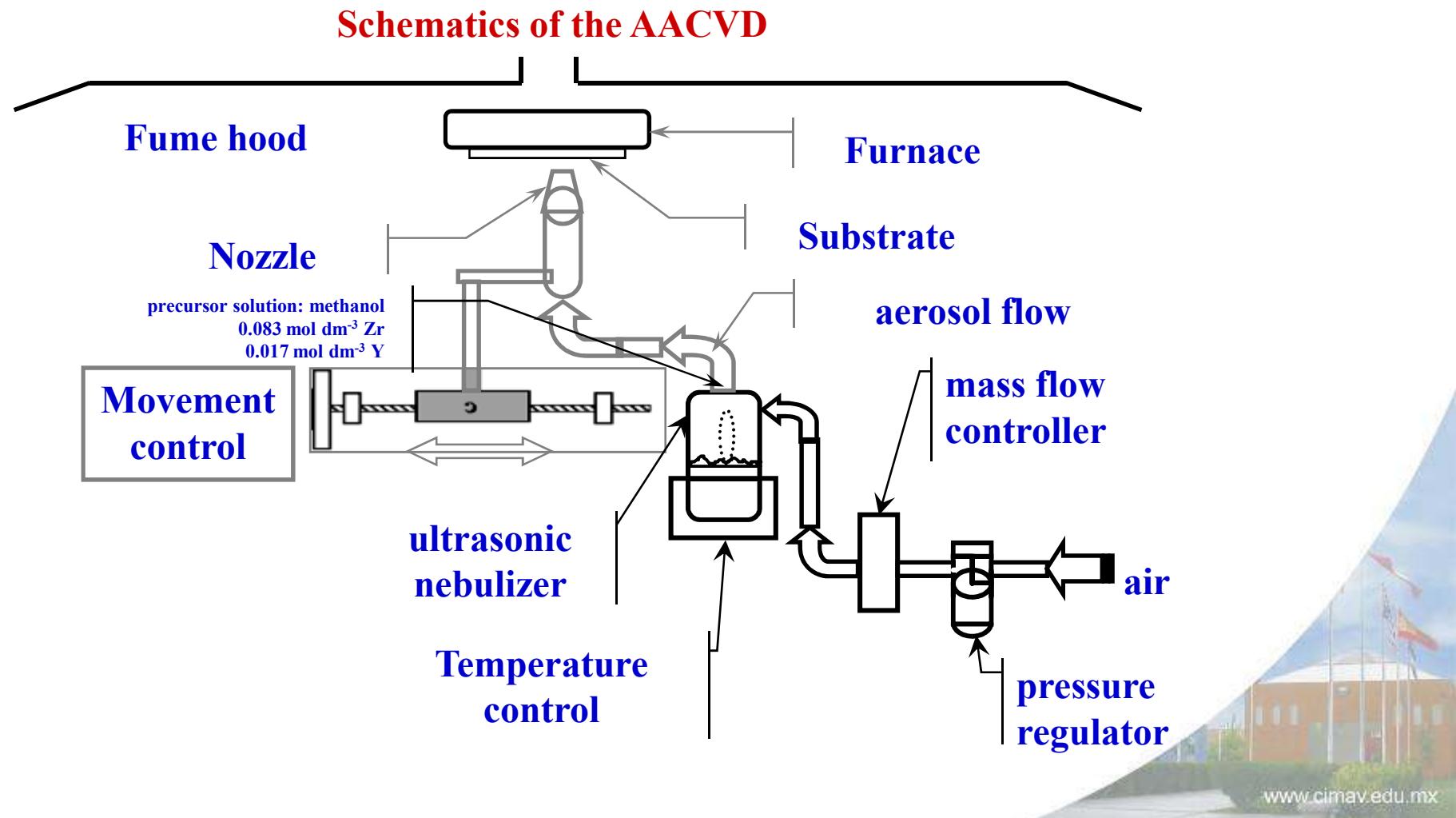
Potential Applications

- Gas adsorbent
- Transparent electronics (ASU/CIMAV)
- Glass industry



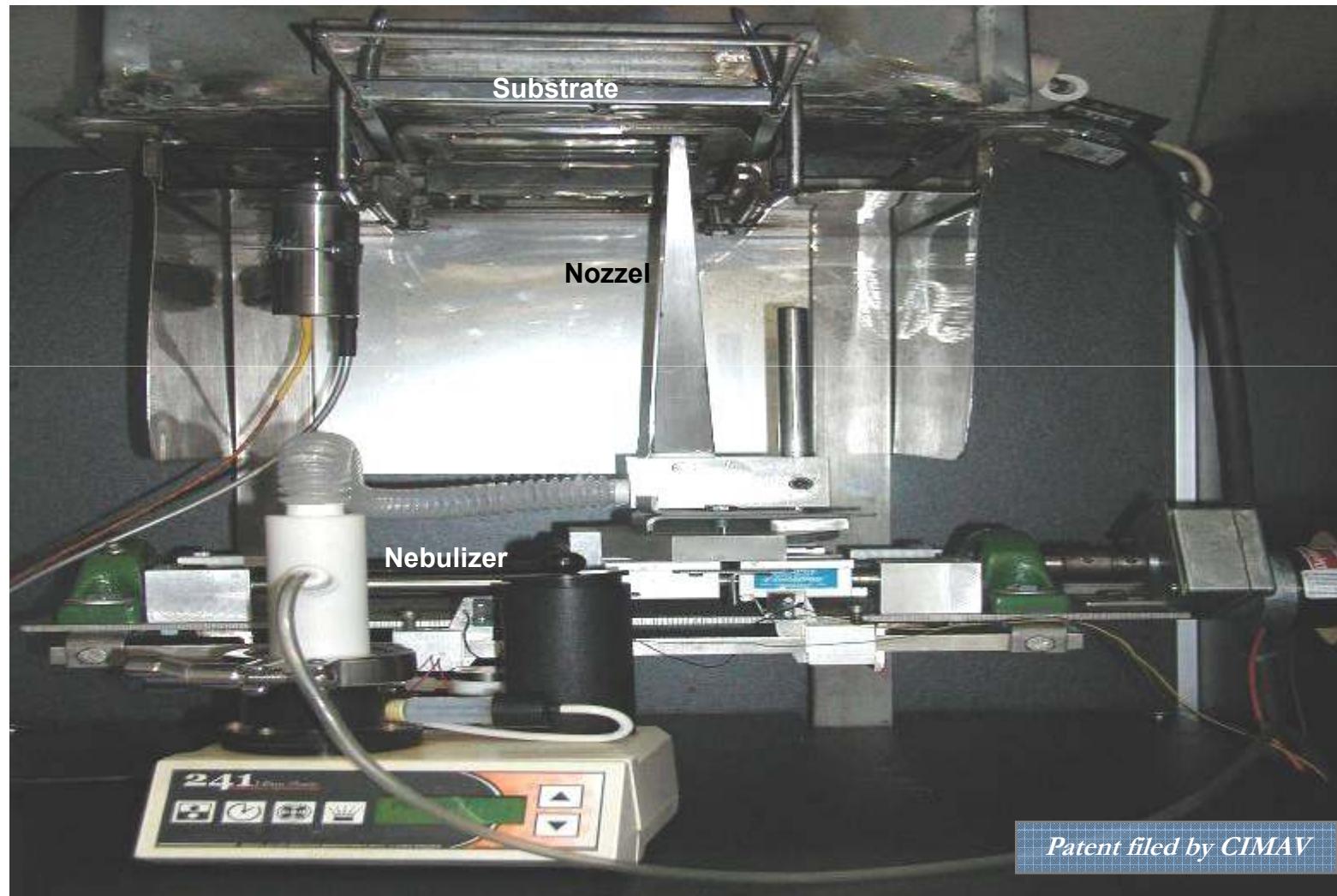
Aerosol Assisted Chemical Vapor Deposition

Application of Nanocoatings

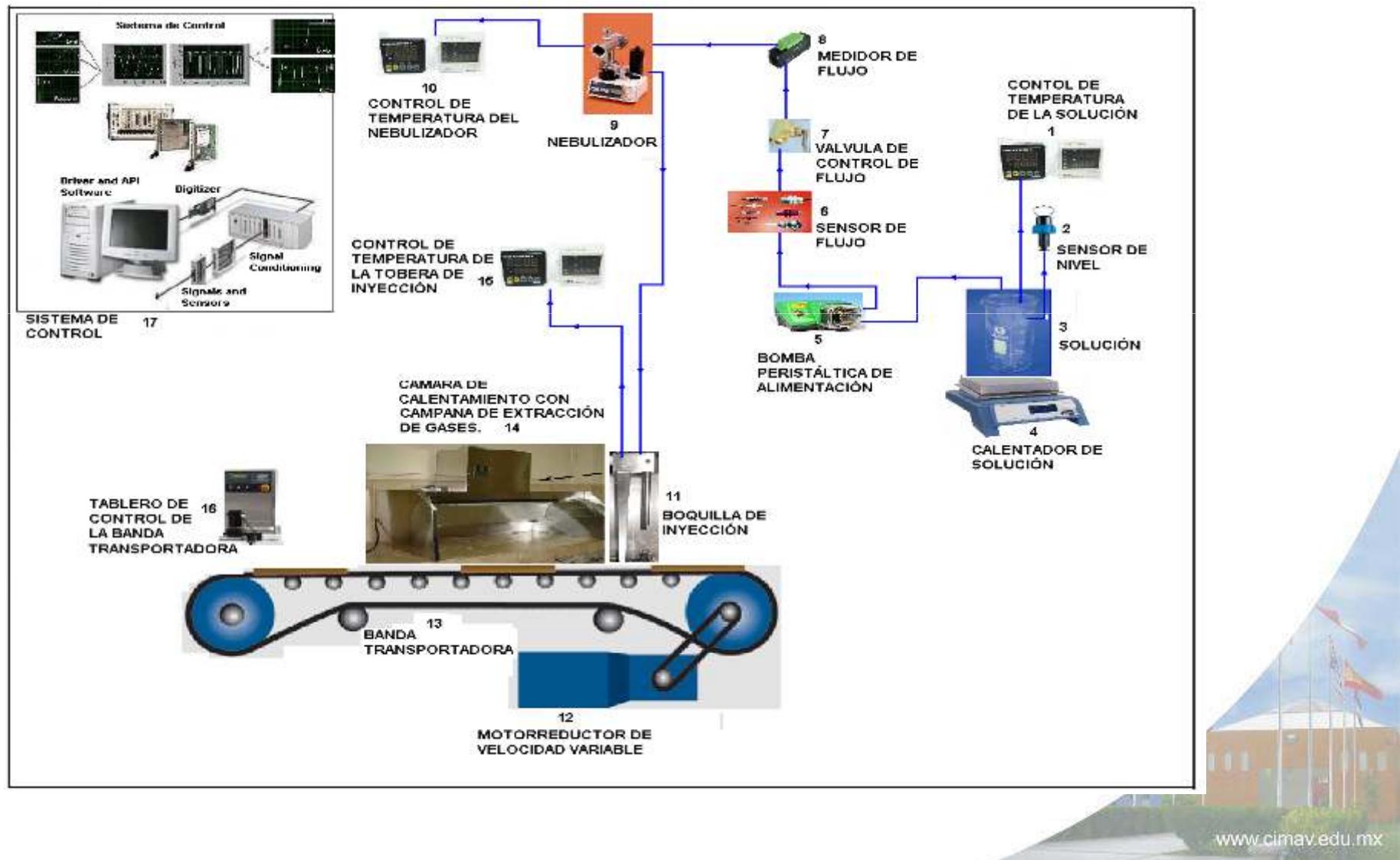


AACVD for Flat Surfaces

Laboratory prototype



AACVD : Lay out of components



General Comments about Nanometrology

- Metrology **appropriate** to nanoscale systems will be critical for the development of nanotechnology, both in terms of the **fundamental scientific** understanding of those systems and in terms of viable **commercial activities**
- It is widely accepted that **no single technique** will be able to provide all of the critical metrology for nanoscale systems
- Ongoing challenges reside in the development of instrumentation built with a level of **sophistication sufficient** to allow their use by scientists in all fields and in the development of **physical understandings** of the factors dictating the response of complex heterogeneous nanometer-scale systems
- **Nanomanufacturing** in the future will rely on **fast in-line metrology tools** for process control, backed up by more accurate tools on the manufacturing floor. Tools will be **cost-effective, fast, suitable for mass production occupy minimal floor space**, not require ultra-high vacuum or stringent vibration isolation and support appropriate work volumes. Real-time data will provide fast analysis and control of manufacturing process.
- Development that has the ability to **characterize dense quantities** of nanoelements under manufacturing conditions and manufacturing-relevant true spans
- Developing effective metrology that enables **in-process measurements** allows companies to take and important step towards achieving predictable product properties.



Thank You